

AI TECHNOLOGY INC 70 Washington Road Princeton Jct., NJ 08550 (609) 799-9388 fax (609) 799-9308 E-Mail: ait@aitechnology.com Internet: http://www.aitechnology.com

Low Bonume Ondernin
Low Moisture Absorption
Low Ionic Impurities
High Temperature Stability
<10 micron cut-off particle

IDEAL FOR:

Flip-chip underfill Ultra-high temperature encapsulation Ideal for 20 micron and higher gap underfilling CTE at 23 ppm/°C: Ideal for solder-bumps

DESCRIPTION:

UF-MC7883-FP is a one part, micro-oxide filled cyanate ester flip-chip underfill. It is designed for use in both chip-on-board underfill and standard flip-chip underfill component application to reduce stress. It can withstand temperatures up to 300°C without thermal degradation. Its unique chemistry results in very low moisture absorption, high strength protection.

UF-MC7883-FP is designed to be dispensed on the edge of flip-chip die for capillary pull-in to fill in the gap before curing. The cured underfill has less than 20 ppm/C in coefficient of thermal expansion and higher than 6 Gpa in modulus.

FLIP-CHIP UNDERFILL

UF-MC7883-FP

TYPICAL PROPERTIES*

Electrical Resistivity (°C/)	>1X10 ¹⁴ ohm-cm	
Dielectric Strength (Volts/mil)	>750	
Glass Transition Temp.(°C)	240 ±10%	
Lap-Shear Strength		
Device Push-off Strength	•	
	>34.4 N/mm²	
Hardness (Type)	95 (D) ±10%	
Cured Density (gm/cc)	2.5 ±10%	
Thermal Conductivity	>5.5 Btu-in/hr-ft²-ºF ±10%	
	>0.8 W/m-ºC ±10%	
Linear Thermal Expansion	23 ±10%	
Coeff. (ppm/ºC)		
Maximum Continuous Operation Temp. (°C) <300		
Avg. Viscosity(5.0 rpm, 25°C)	11,000 cp±15%	
(Brookfield DV-1,spindle CP51)		
roperties given are typical values and not inter	nded for use in preparing specifications	

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AVAILABILITY:

UF-MC7883-FP is available in syringes for automatic dispense applications.

APPLICATION PROCEDURES:

(1) Thaw to room temperature before opening container.

(2) Dispense underfill onto the adjacent edges of die a suitable pattern to assure full die coverage. Allow the underfill to flow and fill the flip-chip at 60-90°C.

(3) Cure according to the recommended schedule, i.e. B-Stage followed by a cure schedule.

NOTE: The monomer contained in this product is subject to crystallization even at room temperature. If product is thawed and remains crystallized, simply place in a 40 deg C environment for as long as needed to return product to the liquid state i.e. usually not more that 15 - 20 minutes.

CURE SCHEDULES:		
<u>Temperature</u>	<u>Time</u>	Pressure
60-90°C	>2min	N/A
for	underfilling followed by curing	
150°C	60 min	
175°C	15min	

Pot life is 5 days @ 25°C. Defrost and use for the same day production only.

For supper low bondline of less than 20 micron meter underfilling, please select MC-7883-FFP with nanotechnology.

For copper stud bumps applications, use UF-MC7883-CU that is engineered with CTE to match copper at 18 ppm/°C.

UF-MC7883-FP can also be used for encapsulation application. Full curing from 80° C for 6 hours or more and less times at higher temperatures.

SHELF LIFE:

Storage temperature	Shelf Life
-40°C	1 yr

CAUTION: This product may cause skin irritation. Avoid skin contact. If contact does occur, wash immediately with soap and water. Please refer SDS for more details.

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